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Journal

Physical Review B. Condensed Matter and Materials Physics, 59(7)

Author

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Publication Date

1998-05-01



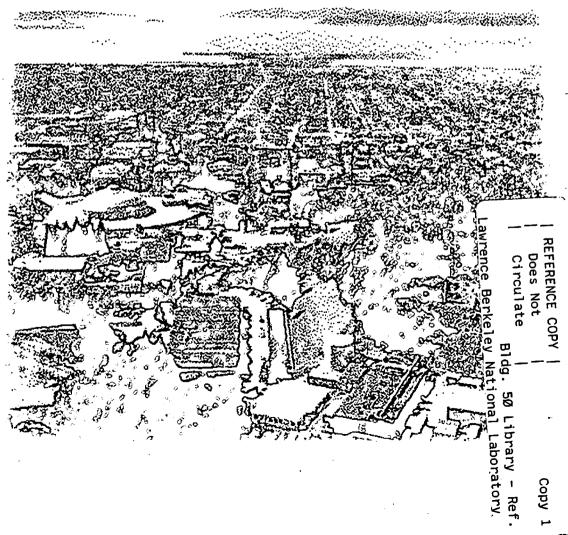
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Band Widening in Graphite

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Advanced Light Source Division

May 1998
Submitted to
Physical Review Letters



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*This work was supported by the Director, Office of Energy Research, Office of Basic Energy Sciences, Materials Sciences Division, of the U.S. Department of Energy, under Contract No. DE-AC03-76SF00098.

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